

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

PATENT

10/A/w/m.

DN 51343

In reapplication of:

Seita et al.

Serial No.: 10/027,919

Filed: December 20, 2001

For: ELECTROLYTIC COPPER PLATING

SOLUTION AND METHOD FOR CONTROLLING THE SAME

: Group Art Unit: 1753

: Examiner: Edna Wong

AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

In response to the Official Action mailed on March 11, 2003, Applicants submit the following amendments and remarks.

Amendments to the Specification begin on page 2 of this paper.

Amendments to the claims are reflected in the listing of claims which begins on page 5 of this paper.

Remarks begin on page 9 of this paper.